MAR 0 6 2002 Practitioner's Docket No.: 782_200

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of: Tomohiko SHIBATA, Yukinori NAKAMURA and Mitsuhiro TANAKA

Ser. No.: 09/997,997

Art Unit: 2834

Filed: November 30, 2001

Examiner: Not Assigned

Confirmation No.: 3908

A SUBSTRATE USABLE FOR AN ACOUSTIC SURFACE WAVE DEVICE, A METHOD FOR FABRICATING THE SAME SUBSTRATE AND AN ACOUSTIC SURFACE WAVE

DEVICE HAVING THE SAME SUBSTRATE

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail addressed to Assistant Commissioner for Patents, Washington D.C. 20231 on February 28, 2002.

Assistant Commissioner for Patents Washington, DC 20231

INFORMATION DISCLOSURE STATEMENT

Sir:

Pursuant to 37 C.F.R. §1.56, the attention of the Patent and Trademark Office is hereby directed to the reference listed on the attached Form PTO-1449. A copy of the reference listed on Form PTO-1449 is attached.

Reference AA is discussed at page 1 of the present specification.

The above information is presented so that the Patent and Trademark Office may, in the first instance, determine any materiality thereof to the claimed invention. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the reference be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

The Commissioner is hereby authorized to charge any additional fees associated with this communication or credit any overpayment to Deposit Account No. 50-1446.

Respectfully submitted.

February 28, 2002 Date

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STATI	INFORMATION DISCLOSURE STATEMENT BY APPLICANT				First Named Inventor		Tomohiko SHIBATA				
					Art Unit		2834				
(use as many sheets as necessary)				Examiner Name		Not Assigned					
			Confirmation No.			3908					
Sheet	1	of	1	Attorney Docket No. 782_200							
				U.S.	PATENT DOCU	MENTS					
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FOREIGN PATENT DOCUMENTS

	Document Number	Date	Country	Class	Sub Class	Translation	Abstract

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages etc.)

AA	S. Kaneko, et al, "Epitaxial Growth of AlN Film by Low-pressure MOCVD in Gas-Beam-Flow Reactor," Journal of Crystal Growth, 115 (1991), pp. 643-647.

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Examiner:	Date Considered:
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